

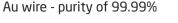


# Tanaka Bonding Wires

TANAKA Bonding wires are used for a wide range of products, such as integrated circuits (ICs and LSIs) and transistors. It allow to connects semiconductor IC chip to electrode.

All of our bonding wires are delivered with a specific certificate of analysis.

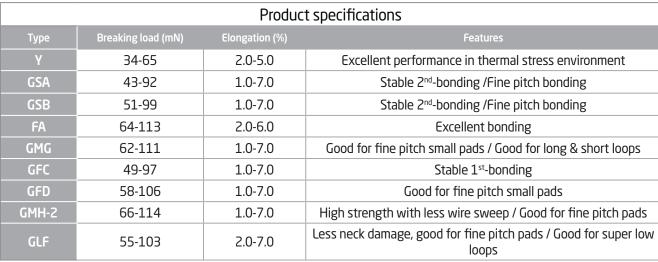
## Gold bonding wire



- Available with various types of package design
- Available with the latest type of package such as stacked package and super thin package
- Use of higher tensile strength wires enables cost reductions with finer diameters
- Use of higher tensile strength wires enables use with fine pitch package

### Size

• Ø from 15 ±1 μm to 38 ±1 μm







TDS-Tanaka Bonding wires\_V2

## Gold alloy bonding wire

Au alloy wire - purity of 99%

- Smaller squashed ball area
- Superior bonding reliability
- Can be used on conventional ball bonders
- No wire bonder stop and no drop of pull strength during continuous bonding
- High bonding reliability when combined with halogen resin
- Stable bonded ball shape. Good ball roundness (GPG-2)

### Size

• Ø from 15 μm to 30 μm

Product specifications						
Туре	Breaking load (mN)	Elongation (%)	Features			
GPG	66-99	1.0-7.0	High reliability with 99.99% Au wires, good for fine pitch pads / Appl			
GPG-2	61-109	1.0-7.0	High reliability with 99.99% Au wires, good for fine pitch pads / Al cable to halogen resin			

## Copper bonding wire

Cu wire - purity of 99.99% and Cu alloy

• Enables a reduction in costs with a lower cost than gold bonding wires



### Size

•  $\emptyset$  from 15 ±1  $\mu$ m to 500 ±10  $\mu$ m

Comparison of Properties of Gold and Copper			
Physical Properties	Au	Cu	
Resistivity [µ0hm.cm]	43-92	1.0-7.0	
Thermal conductivity: [W/m.K]	51-99	1.0-7.0	
Young's modulus: [GPa]	64-113	1.0-7.0	

Product specifications							
Туре	Breaking load (mN)	Elongation (%)	Features				
Cu Alloy (CA-1)	41-93	7.0-17.0	High reliability, good for high 2 <sup>nd</sup> -bonding				
Cu (CFB-1)	43-94	7.0-17.0	High 2 <sup>nd-</sup> bonding / Stable continuous bondability				
Cu (TCA-1)	42-90	5.0-15.0	Good for fine pitch pads / Stable ball formation				
Cu (TCB-1)	27-76	5.0-15.0	Soft and stable ball formation				





## Aluminum bonding wire for power devices

### Al wire - TANW Types

- Excellent corrosion resistance
- Excellent bondability
- Hard, Soft-1, and Soft-2 are available according to applications

### Size

• Ø from 100  $\pm$ 5 µm to 500  $\pm$ 10 µm

## Aluminum-Silcon bonding wire

### Al 1%/Si wire - TABN Types

- Uniform Si distribution
- Stable mechanical properties
- Stable quality wire without any curl, dirt and suface flaws
- Excellent bondability
- Excellent corrosion resistance



### Size

• ø from 18 ±1  $\mu$ m to 80 ±3  $\mu$ m

## Silver alloy bonding wire

### Ag wire - SEA, SEB, SEC Types

- Lower material costs than gold wire and higher bondability than copper wire
- High reflectivity in low wavelength region



### Size

• ø from 15 μm to 30 μm



